

Supplementary Information

Dirac-Fermion-Assisted Interfacial Superconductivity in Epitaxial Topological-Insulator/Iron-Chalcogenide Heterostructures

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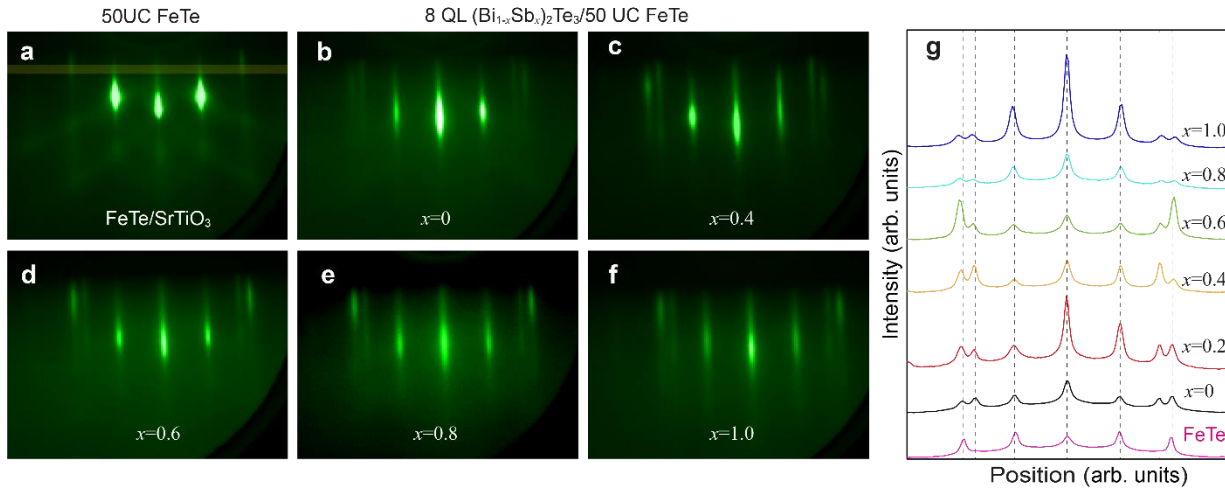
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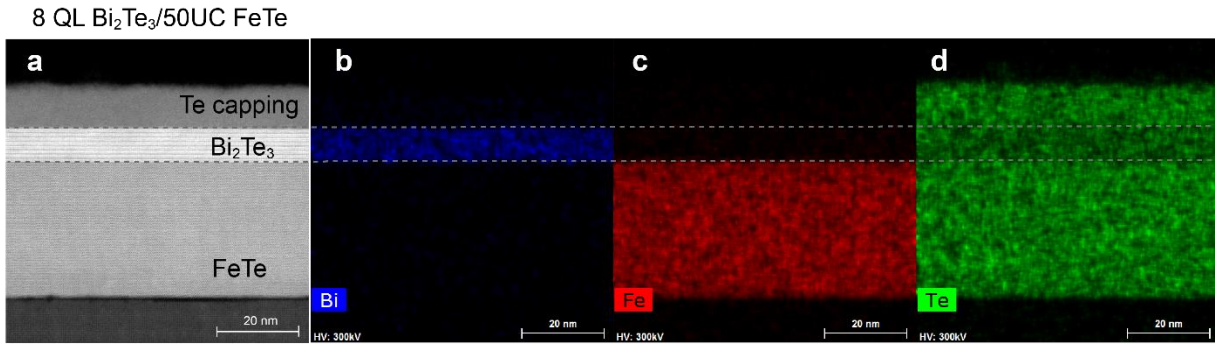
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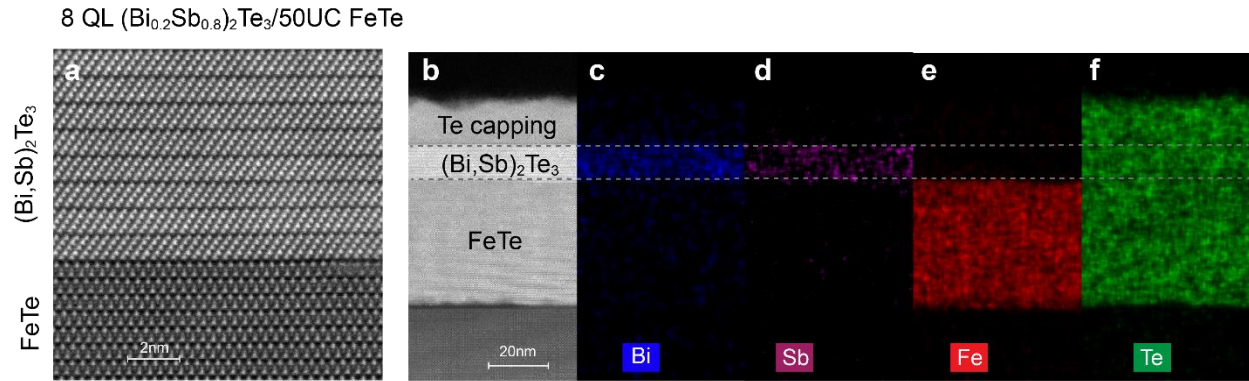
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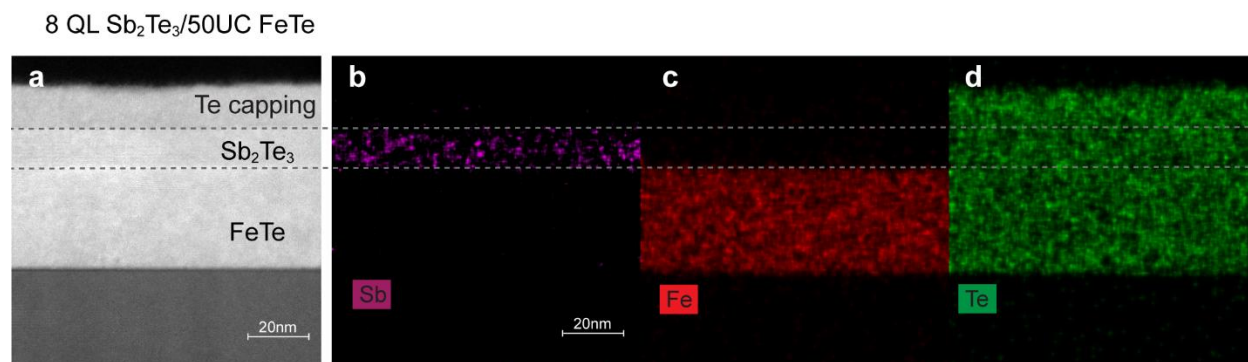
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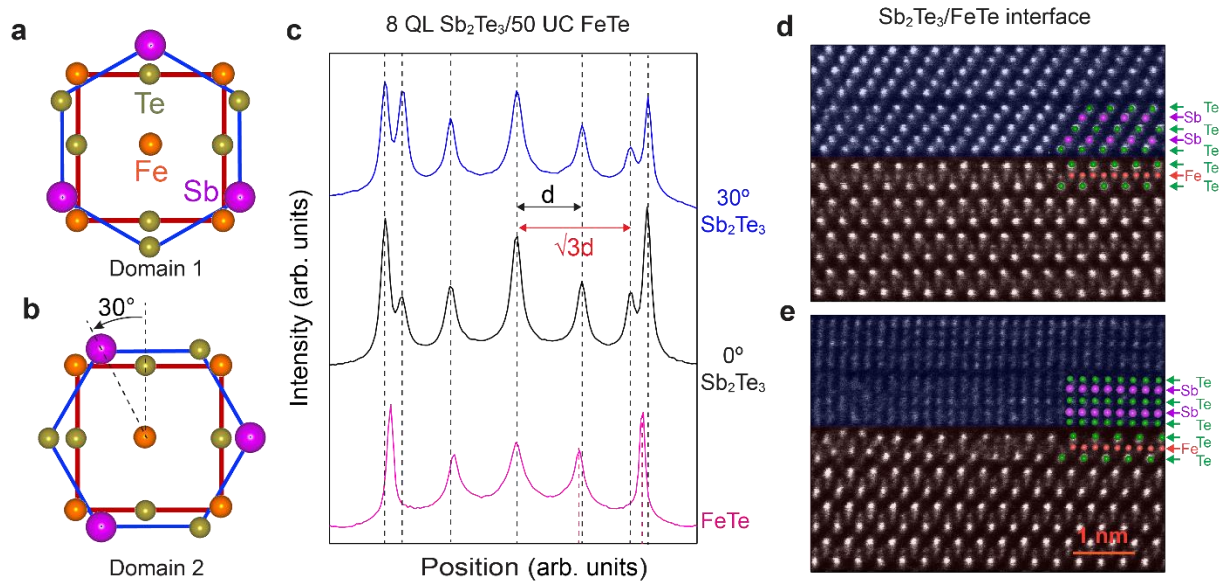
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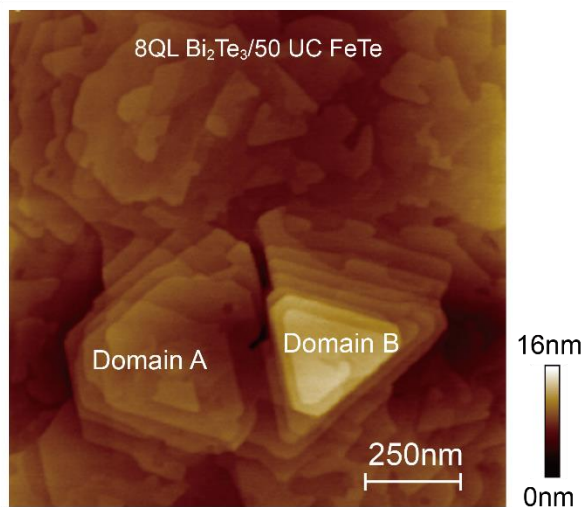
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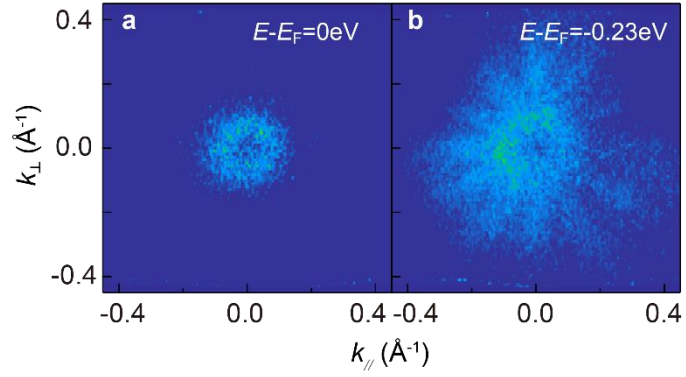
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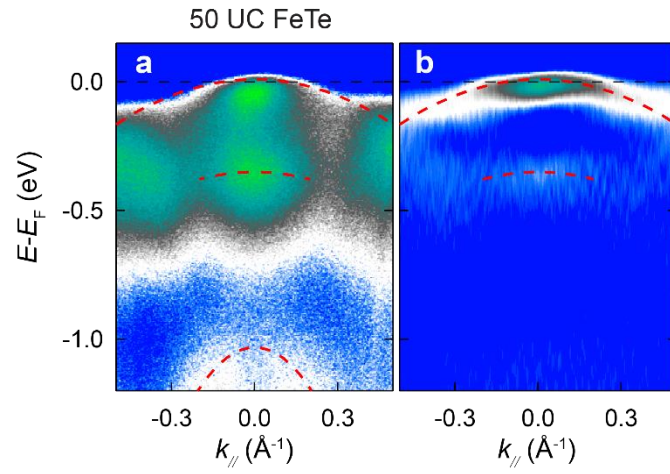
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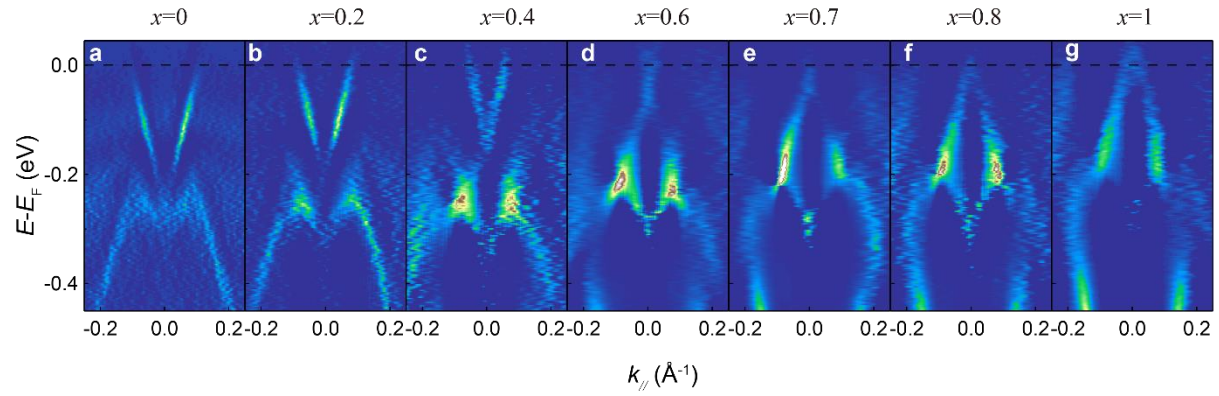
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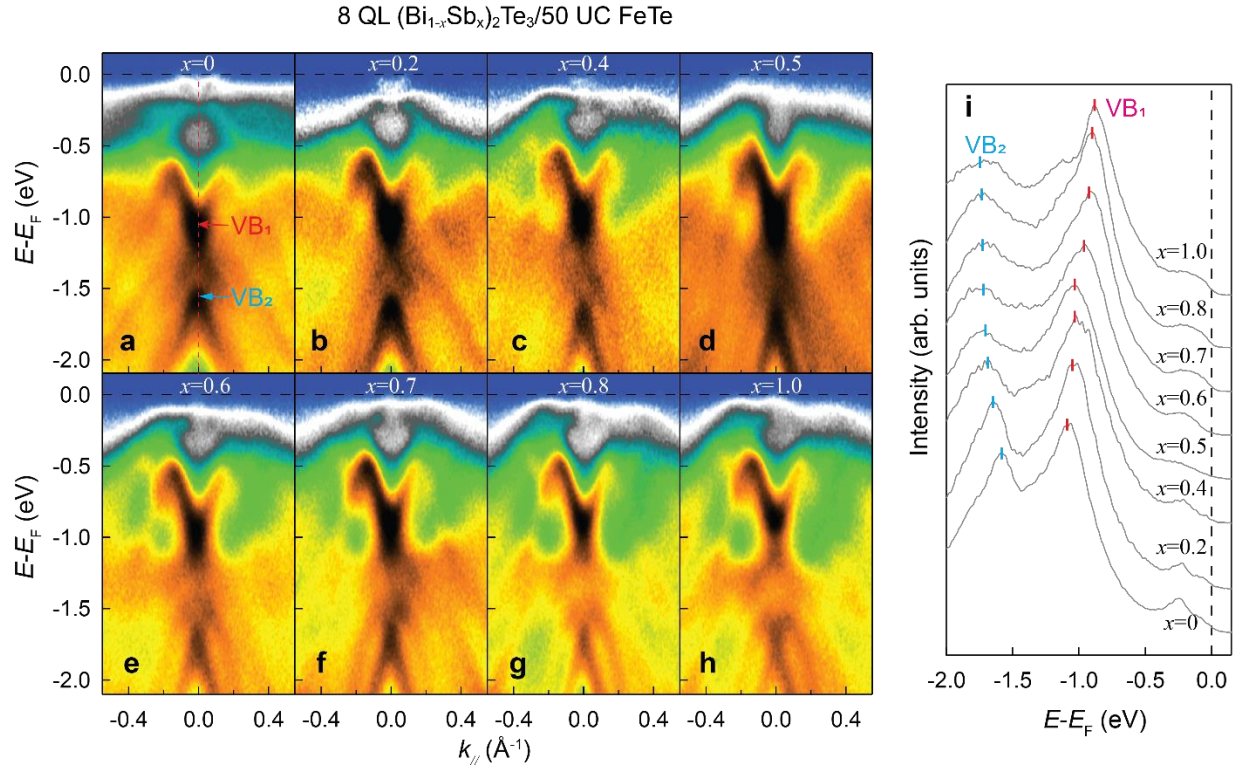
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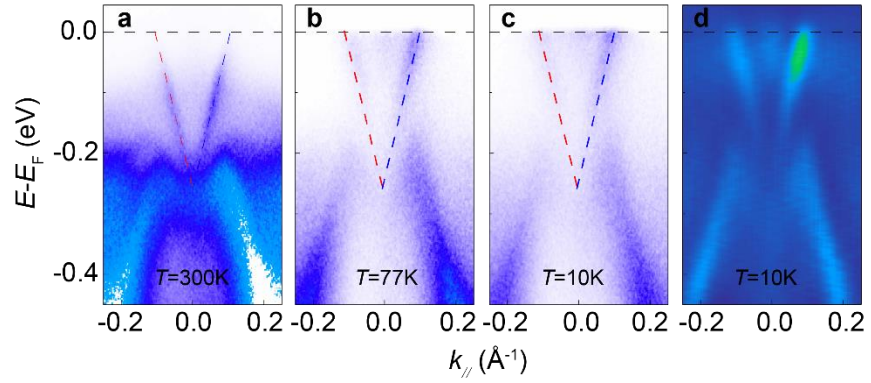
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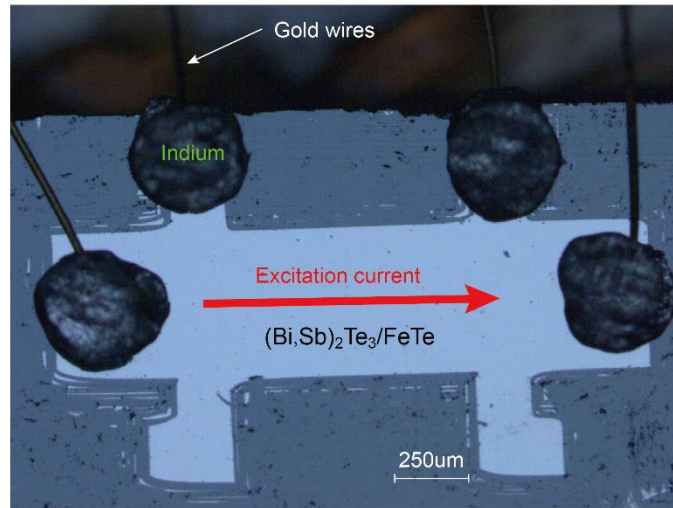
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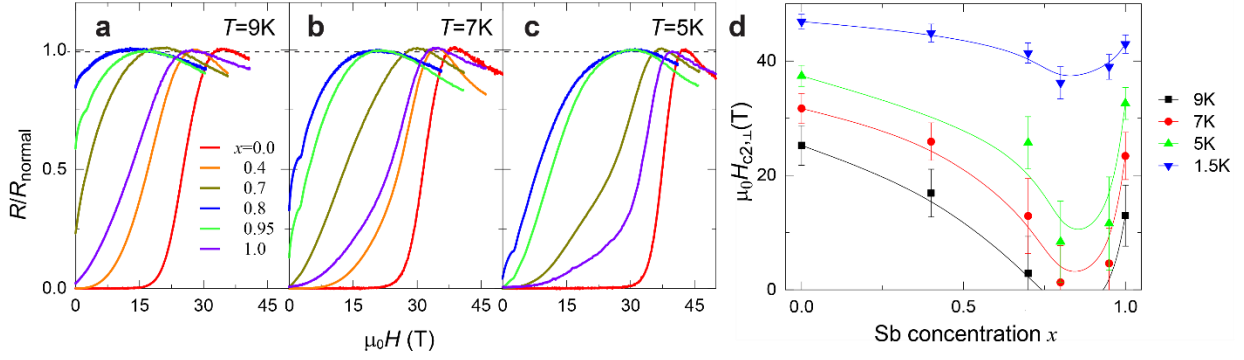
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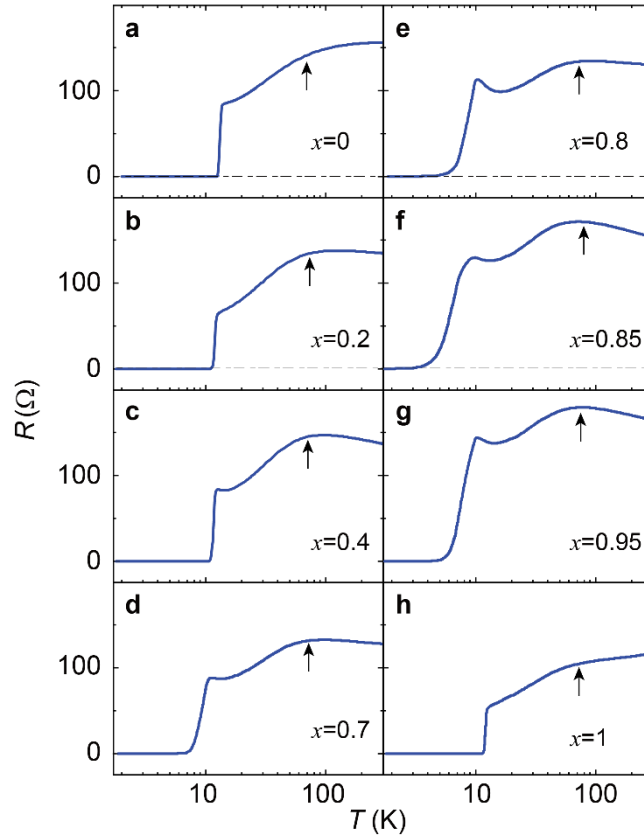
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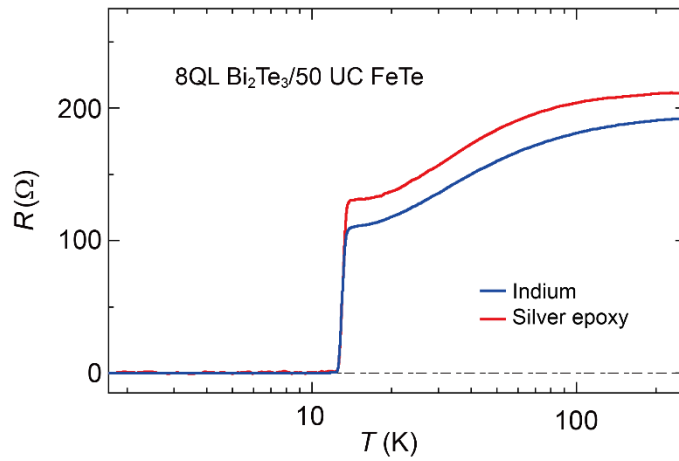
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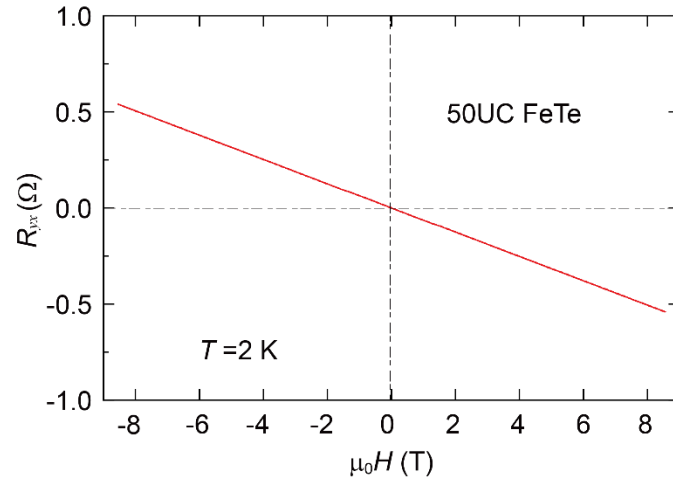
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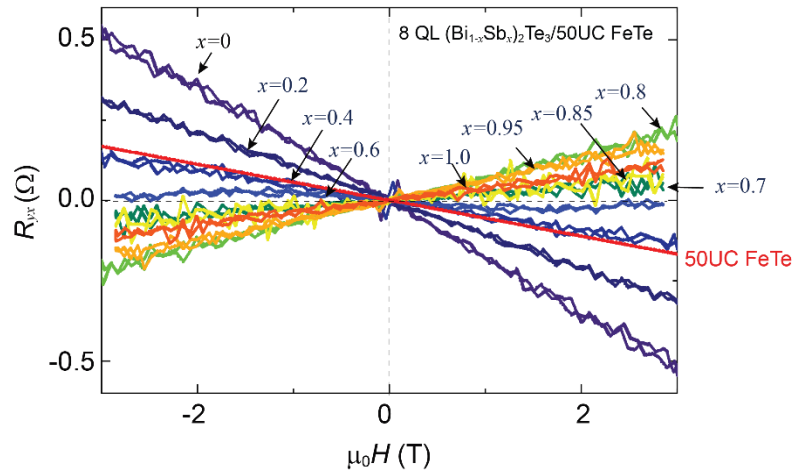
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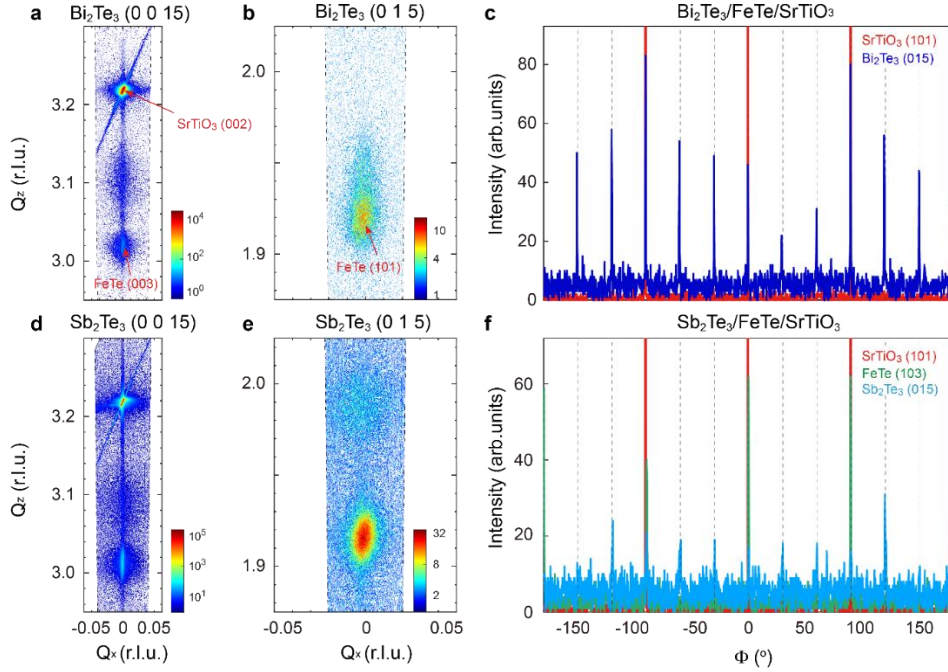
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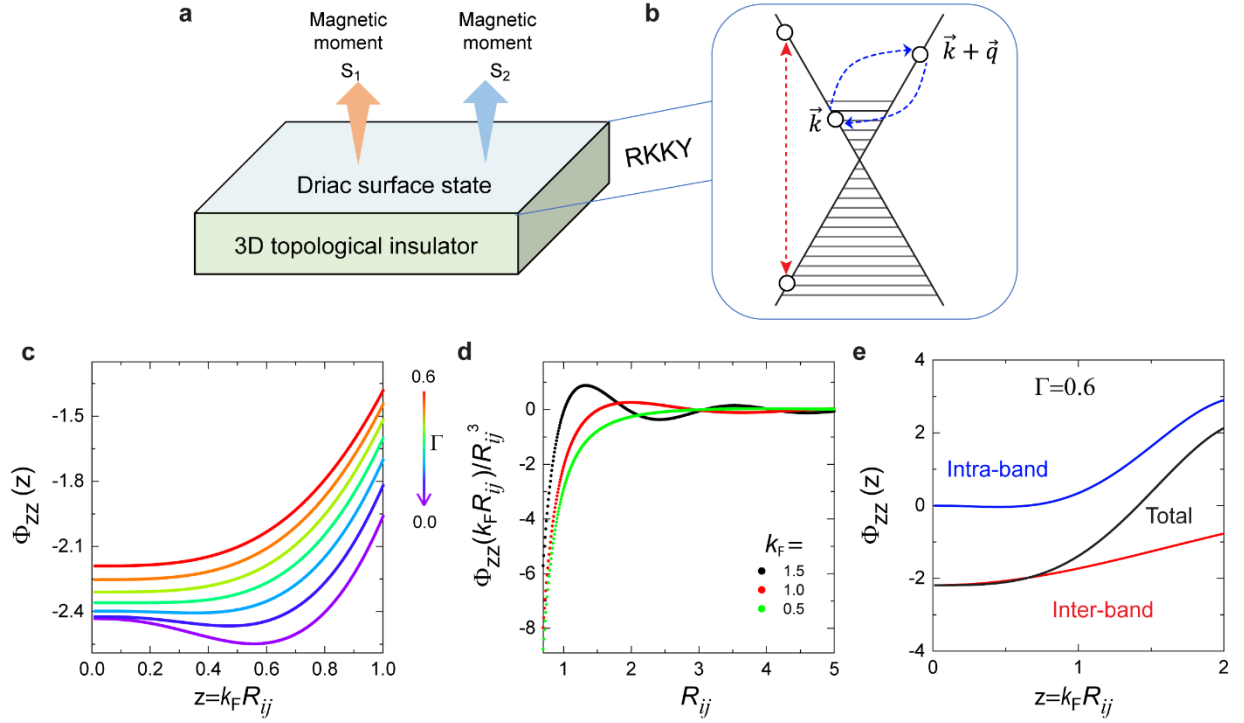
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Supplementary Fig. 17| Hall traces of all 8 QL $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3/50\text{UC FeTe}$ heterostructures with interfacial superconductivity and 50 UC FeTe layer without superconductivity. All measurements are taken at $T=30$ K.



Supplementary Fig. 18 | XRD reciprocal space mapping (RSM) of the Bi₂Te₃/FeTe and Sb₂Te₃/FeTe heterostructures. **a**, Symmetric RSM around the Bi₂Te₃ (0 0 15) peak showing SrTiO₃ (0 0 2) and FeTe (0 0 3) reflections. The dotted lines show the extent of the scanned region in reciprocal space. **b**, Symmetric RSM measured at $\chi=58.08^\circ$ showing Bi₂Te₃ (0 1 5) peak partially overlapped with FeTe (1 0 1). **c**, ϕ scans of Bi₂Te₃ and SrTiO₃. Bi₂Te₃ shows twin domains with a 30° rotation. **d**, RSM of Sb₂Te₃ (0 0 15) showing SrTiO₃ and FeTe as in (a). **e**, RSM measured at $\chi=58.78^\circ$ showing Sb₂Te₃ (0 1 5) at a larger Q_z than the corresponding Bi₂Te₃ peak due to the smaller in-plane lattice constant of Sb₂Te₃. **f**, ϕ scans of Sb₂Te₃, FeTe and SrTiO₃. FeTe is epitaxial to SrTiO₃ substrate while Sb₂Te₃ shows twin domains with a 30° rotation.



Supplementary Fig. 19 | Dirac-electrons-induced RKKY interaction between two adjacent magnetic moments. **a**, Schematics of two magnetic moments on a TI surface. \vec{S}_1 and \vec{S}_2 are coupled with each other through exchange spin-spin interaction via itinerant Dirac electrons. **b**, RKKY interaction mechanism between \vec{S}_1 and \vec{S}_2 . The stripe region displays the occupied states of Dirac electrons. The blue and red dashed lines are the intra-band and inter-band scatterings via the exchange coupling between the magnetic moments and Dirac electrons, respectively. The RKKY coupling strength was calculated using the second-order perturbation theory. **c**, RKKY interaction $\Phi_{zz}(z)$ as a function of z at different disorder broadening Γ . $z = k_F R_{ij}$ is a dimensionless parameter, and R_{ij} is the spatial distance between two magnetic moments. For $\Gamma \geq 0.3$, Φ_{zz} shows a monotonic z dependence. **d**, The RKKY interaction strength as a function of R_{ij} at different k_F for a fixed $\Gamma = 0.6$. **e**, RKKY interaction $\Phi_{zz}(z)$ as a function of z at disorder broadening $\Gamma = 0.6$. Both intra-band and inter-band scatterings contribute to the total RKKY interaction. As k_F approaches 0, the contribution from intra-band scattering vanishes.

II. Supplementary Text

1. Influence of the disorder effect on interfacial superconductivity in TI/FeTe

In our theoretical calculations, the influence of the disorder on magnetic interaction can be included in an imaginary self-energy broadening $i\Gamma$ in the Green's function (Methods). The disorder may also give rise to a real part of the self-energy, which might cause a renormalization effect on the Dirac surface states of TI (Ref. ¹). The real part of self-energy can provide corrections to the energy of Dirac points and the velocity of the Dirac surface states, both of which are directly extracted from the experimental data. Therefore, the parameters used in our theory can be treated as “renormalized” values.

Moreover, the disorder in $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3$ has been found to be maximized near $x=0.5$, i.e., the compositions of Bi and Sb are equal, through thermal conductivity measurements ². However, in our experiments, the dip feature in both T_c and $\mu_0 H_{c2,\perp}$ appears near $x=0.85$ (Figs. 4c and 4d), which is far from the position for the maximum disorder but close to the Dirac point of the surface states (i.e., $x=0.8$) (Fig. 4a). These observations also rule out the possibility that the appearance of the dip features in both T_c and $\mu_0 H_{c2,\perp}$ is a direct result of the disorder effect in the TI layer.

2. Massive and massless Dirac fermions in TI thin films

For the TI thin films in the 2D regime, a hybridization gap is formed between the top and bottom surface states ³⁻⁶, which leads to the Dirac fermions acquiring mass (or a gap) and thus makes Dirac fermions massive ^{7,8}. We note that the terminology of “Dirac fermions” remains consistent regardless of the TI thickness. Our theoretical analysis remains applicable to both massless and massive Dirac fermions. In Supplementary Fig. 19, we have demonstrated that both intra-band scattering and inter-band scattering give rise to the RKKY interaction. In particular, when the chemical potential is close to the Dirac point, the intra-band contribution is negligible due to the vanishing density of states at the Dirac point while the inter-band contribution is the dominant mechanism. In the case of massive Dirac fermions, the inter-band contribution plays a primary role in RKKY interaction and is of ferromagnetic type when the Fermi energy is inside the Dirac fermion gap. This inter-band contribution is also known as the van Vleck mechanism ⁹ or the Bloembergen-Rowland mechanism ¹⁰, which is known to play an important role in inducing ferromagnetism in magnetically doped TI films ¹¹.

3. Hall traces of the $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3/\text{FeTe}$ heterostructures

We perform the Hall measurements on all 8 QL $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3/50\text{UC FeTe}$ heterostructures with interfacial superconductivity (Supplementary Fig. S17) and the 50 UC FeTe layer without superconductivity (Supplementary Figs. S16 and S17). We find that the absolute values of the Hall trace slopes are small for all these samples. Moreover, for $0 \leq x \leq 0.6$, the Hall traces of these $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3/\text{FeTe}$ heterostructures show systematic behavior, and the Hall trace slope decreases with increasing x . However, for x is near 0.85, i.e., $0.7 \leq x \leq 1.0$ and the chemical potential is near the Dirac point of the TI layer, the Hall traces show some fluctuations (Supplementary Fig. S17).

Next, we employ a two-layer structure to model the TI/FeTe heterostructure and performed simple calculations to understand our observations. To simplify our calculations, we ignore the charge transfer effect between TI and FeTe layers. The total Hall resistance of the TI/FeTe bilayer can be calculated using the following equation:

$$R_{yx} = \left(\frac{R_{yx}^{\text{FeTe}} + R_{yx}^{\text{TI}}}{\left(\frac{1}{R_{xx}^{\text{FeTe}}} + \frac{1}{R_{xx}^{\text{TI}}} \right)^2} \right) \quad (1)$$

Since the FeTe layer exhibits higher conductivity compared to the $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3$ layer (Fig. 1c), R_{xx}^{FeTe} is much less than R_{xx}^{TI} (i.e., $R_{xx}^{\text{FeTe}} \ll R_{xx}^{\text{TI}}$) (Ref. 12). Given this assumption, we can simplify Equation (1):

$$R_{yx} = \left(R_{yx}^{\text{FeTe}} + R_{yx}^{\text{TI}} * \left(\frac{R_{xx}^{\text{FeTe}}}{R_{xx}^{\text{TI}}} \right)^2 \right) = \left(R_{yx}^{\text{FeTe}} + \frac{R_{yx}^{\text{TI}}}{(R_{xx}^{\text{TI}})^2} * (R_{xx}^{\text{FeTe}})^2 \right) \quad (2)$$

Therefore, the total Hall resistance R_{yx} value of the TI/FeTe heterostructure is determined by the jointed contribution of the Hall resistance of the FeTe layer R_{yx}^{FeTe} and the modified Hall resistance of the TI layer $R_{yx}^{\text{TI}} * \left(\frac{R_{xx}^{\text{FeTe}}}{R_{xx}^{\text{TI}}} \right)^2$. For all $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3/\text{FeTe}$ heterostructures, both R_{xx}^{FeTe} and R_{yx}^{FeTe} are assumed to be constant. Systematic change in x can affect both R_{xx}^{TI} and R_{yx}^{TI} . For $0 \leq x \leq 0.6$, the value of $\frac{R_{yx}^{\text{TI}}}{(R_{xx}^{\text{TI}})^2}$ remains relatively insensitive to x and thus results in systematic behaviors in R_{yx} of the TI/FeTe heterostructures. However, for $0.7 \leq x \leq 1.0$,

specifically when the chemical potential is near the Dirac point of the TI layer, the value of $\frac{R_{yx}^{TI}}{(R_{xx}^{TI})^2}$ becomes more sensitive to x and thus leads to fluctuations in the Hall traces. We note that the carrier type of the FeTe layer is n -type (Supplementary Figs. S16 and S17), a change in the Hall trace sign of the $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3/\text{FeTe}$ heterostructures is in the range of $0.6 < x < 0.7$, as opposed to occurring beyond $x=0.8$, where the chemical potential crosses the Dirac point based on ARPES (Figs. 2 and 4a). This observation also suggests that there is no substantial charge transfer effect between the $(\text{Bi}_{1-x}\text{Sb}_x)_2\text{Te}_3$ layer and FeTe layers.

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